IN THE CLAIMS:

Claims 2 through 16 have been amended herein. All of the pending claims 1 through 16 are presented below. This listing of claims will replace all prior versions and listings of claims in the application. Please enter these claims as amended.

Listing of Claims:

- (Previously presented) A method for bonding a conductive element to a contact
 of a semiconductor device component, comprising:
 providing a semiconductor device component with at least one contact; and
 defining at least two layers of at least one conductive element from corresponding layers
 comprising substantially unconsolidated conductive material.
- 2. (Currently Amended) The method of claim 1, wherein said-defining comprises causing said substantially unconsolidated conductive material in selected regions of each of said corresponding layers to at least partially consolidate.
- 3. (Currently Amended) The method of claim 1, further comprising, following said defining, permitting said substantially unconsolidated conductive material to at least partially consolidate.
- 4. (Currently Amended) The method of claim 1, wherein said providing said semiconductor device component comprises providing a carrier substrate.
- 5. (Currently Amended) The method of claim 1, wherein said-providing said semiconductor device component comprises providing a semiconductor die.

- 6. (Currently Amended) The method of claim 1, wherein said-providing said semiconductor device component comprises providing a packaged semiconductor device.
- 7. (Currently Amended) The method of claim 1, wherein said-defining comprises defining said at least two layers from an at least partially liquified thermoplastic conductive elastomer.
- 8. (Currently Amended) The method of claim 7, further comprising, following said defining, permitting said at least partially liquified thermoplastic conductive elastomer to at least partially consolidate.
- 9. (Currently Amended) The method of claim 8, wherein said_permitting said_at least partially liquified thermoplastic conductive material_elastomer to at least partially consolidate comprises permitting said_at least partially liquified thermoplastic conductive material_elastomer to at least partially harden.
- 10. (Currently Amended) The method of claim 1, wherein said-defining comprises defining said at least two layers from an at least partially uncured conductive photopolymer.
- 11. (Currently Amended) The method of claim 10, wherein said-defining comprises causing said at least partially uncured conductive photopolymer to at least partially consolidate.
- 12. (Currently Amended) The method of claim 11, wherein said-causing said at least partially uncured conductive material photopolymer to at least partially consolidate comprises directing a laser beam onto selected regions of at least one of said corresponding layers of substantially unconsolidated conductive material.

- 13. (Currently Amended) The method of claim 1, wherein said-defining comprises defining said at least two layers from metal particles.
- 14. (Currently Amended) The method of claim 13, wherein said defining comprises defining said at least two layers from resin-coated metal.
- 15. (Currently Amended) The method of claim 13, wherein said-defining comprises securing said metal particles in selected regions of said <u>corresponding</u> layers of substantially unconsolidated conductive material to adjacent metal particles.
- 16. (Currently Amended) The method of claim 15, wherein said securing comprises directing an energy beam onto selected regions of said <u>corresponding</u> layers of substantially unconsolidated conductive material.

IN THE DRAWINGS:

The attached sheet of drawings includes a change to FIG. 12. This sheet replaces the original sheet including FIG. 12.

Specifically, FIG. 12 has been revised to lengthen the horizontal dashed line and add the reference numeral --188-- with appropriate lead line extending to the lengthened horizontal dashed line. No new matter has been added.